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Thin Solid Films 323 (1998) 317–318

thin solid films

# Author Index of Volume 323

Ahn, B.T. 265
Alexandrescu, R. 72
Ali-Adib, Z. 227
Ali, A.O. 105
Allahverdi, K. 194
Ausserré, D. 1
Avasthi, D.K. 163

Baek, W.-S. 146
Bahtat, A. 59
Bahtat, M. 59
Balogh, D.T. 257
Bao, X.-M. 68
Basceri, C. 285
Bendahan, M. 31
Berry, A. 10
Blanche, C. 42
Borsella, E. 291
Bouazaoui, M. 59
Bouderbala, M. 59
Boulouz, A. 85
Boulouz, M. 85
Boyer, A. 85
Brahamprakash, 163

Chan, H.L.W. 270
Chao, I.-N. 126
Chen, D. 217
Chen, G. 309
Chen, Y. 270
Cheng, W.Q. 174
Chopra, D. 170
Choy, C.L. 270
Chrysicopoulou, P. 188
Chumash, V. 72
Cojocaru, I. 72
Comes, F.J. 115

Davazoglou, D. 188
Dávid, L. 212
De Padova, P. 291
Dhanabalan, A. 257
Dharmadhikari, C.V. 105
Dieguez Campo, J.M. 115
Dilawar, N. 163
Dimitrov, D. 79
Doo-Young Yang, 285
Druetta, M. 59
Dukarov, S.V. 136
Dunn, D. 10
Dunne, D. 227

Erkoç, Ş. 194

Faglia, G. 291
Fan, S. 304
Fartash, A. 296
Fujimoto, T. 99

Galdikas, A. 275
Ghica, C. 72
Giacometti, J.A. 257
Giani, A. 85
Gibaud, A. 1
Grübel, G. 1
Gueorguiev, Y. 222
Guillén, C. 93
Gyorgy, E. 72

Hagfeldt, A. 141
Harms, U. 153
Haroutyunian, S.L. 209
Haroutyunian, V.A. 209
He, J. 183
Henningsson, A. 141
Herrero, J. 93
Ho, P.S. 203
Hodge, P. 227
Huang, Q. 174

Iliadis, A.A. 37
Inaba, M. 18

Jones, K.A. 37

Kabiraj, D. 163
Kapil, R. 163
Katircioğlu, Ş. 194
Kazarian, E.M. 209
Ke, N. 217
Kempen, L. 153
Kikuchi, K. 18
Kim, H.-G. 285
Kim, S.K. 265
Kingon, A.I. 285
Knauth, P. 31
Kojima, I. 99
Kola, R.R. 6
Kondo, W. 99
Kordas, G. 188
Kovacheva, D. 79
Kovács, B. 212
Kovaļova, O. 23
Kshirsagar, R.B. 105
Kučírková, A. 53
Kumagai, T. 99

Kwon, S.-C. 146
Kwon, S.H. 265

Lábár, J. 212
Ladouceur, H. 10
Lan, W.-Z. 235
Larciprete, R. 291
Lareau, R.T. 37
Lee, J.-Y. 146
Lee, S.-R. 146
Lee, W.-J. 285
Lenski, M. 115
Lepienski, C.M. 178
Li, C. 158
Li, M. 304
Li, Y.X. 37
Lindquist, S.-E. 141
Lindström, H. 141
Liou, H.-C. 203
Liu, H.-G. 235
Liu, W. 158
Lollmun, G. 31
Luches, A. 72

Ma, D. 183
Ma, G. 309
Manabe, T. 99
Mattoso, N. 178
Mazzaro, I. 178
McCann, P.J. 126
McKeown, N.B. 227
Mehta, G.K. 163
Mihailescu, I.N. 72
Mineshige, A. 18
Mironas, A. 275
Mizuta, S. 99
Mladenov, G. 222
Mojzes, I. 212
Mosca, D.H. 178
Mouanda, B. 42
Mowery, R. 10
Mugnier, J. 59

Nakanishi, S. 18
Nam, K.-S. 146
Navrátil, K. 53
Neuhäuser, H. 153
Nishimura, I. 18

Ogumi, Z. 18
Oliveira Jr., O.N. 257
O'Rear, E.A. 126

Paris, F. 1
Park, Y. 285
Pasquinelli, M. 31
Pécz, B. 212
Pelēcis, M. 23
Peng, C.S. 174
Peng, S. 217
Perfetti, P. 291
Perrone, A. 72

Ramesh, R. 37
Rensmo, H. 141
Rha, J.-J. 146
Riul Jr., A. 257
Rubene, V. 23

Salamanca-Riba, L.G. 37
Sberveglieri, G. 291
Schasfoort, A. 243
Schouten, A.J. 243, 251
Schreiner, W.H. 178
Seguin, J.-L. 31
Seitzman, L. 10
Senthil Kumar, P. 110
Senulienė, D. 275
Šetkus, A. 275
Sharma, R.P. 37
Sheng, T.T. 174
Siegbahn, H. 141
Södergren, S. 141
Song, J. 265
Song, Y. 199
Streiffer, S.K. 285
Sugii, N. 63
Sun, Y. 158
Sunandana, C.S. 110
Suni, I.I. 170

Takagi, K. 63
Talyansky, V. 37
Tasaka, A. 18
Teixeira, S.R. 178
Trapalis, Chr. 188
Tung, C.H. 174
Turner, N.H. 10
Tzocheva, D. 79

Vankar, V.D. 163
Venkatesan, T. 37
Viel, P. 42
Vignaud, G. 1
Vispute, R.D. 37

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*PII* S0040-6090(98)00833-5

Vītiņa, I. 23
Vutova, K. 222

Wang, M. 199
Wang, Z.-L. 304
Wei, A. 217
Werckmann, J. 72
Werder, D.J. 6
Werkman, P.J. 243, 251
West, D. 227
Wieringa, R.H. 243, 251
Willecke, R. 203
Wong, S.P. 217
Wood, M.C. 37
Wu, W. 199

Xiong, G. 304
Xu, K. 183

Yamaguchi, I. 99
Yang, K.-Z. 235
Yang, S. 158
Yang, Y. 199
Ye, Y.-H. 68
Yoon, K.H. 265
Yuan, S. 126
Yuan, W.-L. 126

Zālīte, I. 23
Zemek, J. 53
Zhang, H.-W. 235
Zhang, J.-Y. 68
Zhang, Y.H. 174
Zhao, Q.-T. 304
Zhou, J.M. 174
Zhu, G.-Y. 235

ELSEVIER

Thin Solid Films 323 (1998) 319–323

thin solid films

# Subject Index of Volume 323

Adhesion
The effect of Ti ion bombardment on the interfacial structure between TiN and iron nitride, 146
Adsorption
Electric field effect on exciton absorption in size-quantized semiconductor film, 209
γ-AgI
γ-AgI films by iodization at ambient temperature, 110
Alkoxysilanes
Surface characterization of a potential photoactive LC coupling agent, 42
Aluminum nitride
Fabrication and characterization of epitaxial AlN/TiN bilayers on sapphire, 37
Amorphous carbon films
Size and temperature effects on wetting in supercooled vacuum condensates, 136
Amorphous materials
Calorimetric study of amorphous Sb–Se thin films, 79
Multi-pass overlapping laser glazing of FeCrPC and CoNiSiB alloys, 199
Anatase
Redox properties of nanoporous $TiO_2$ (anatase) surface modified with phosphotungstic acid, 141
Anodization
Microstructure of $Ta_2O_5$ films grown by the anodization of $TaN_x$, 6
Auger electron spectroscopy (AES)
Depth inhomogeneity of deposited thin films: application to semi-insulating polycrystalline silicon films, 53
Azo dyes
Properties of polymeric Langmuir–Blodgett films containing sulphonyl-substituted azobenzene moieties for second harmonic generation, 227

Black layer
The effect of Ti ion bombardment on the interfacial structure between TiN and iron nitride, 146
Bottom electrode structures
Ir and Ru bottom electrodes for (Ba, Sr)$TiO_3$ thin films deposited by liquid delivery source chemical vapor deposition, 285
BPDA-PDA
Study of out-of-plane elastic properties of PMDA-ODA and BPDA-PDA polyimide thin films, 203

Carbon
Friction and wear behaviour of carbon ion-implanted PS against steel, 158
Carbon nitride thin films
Optical studies of carbon nitride thin films deposited by reactive pulsed laser ablation of a graphite target in low pressure ammonia, 72
$C_{60}$/Au interface
In-plane orientational order across $C_{60}(111)/Au(111)$ interfaces, 296

Ceria
Preparation of ceria thin films and microtubes by vapor-phase deposition using NiO as oxygen source, 18
Chemical gas sensors
Organotin films deposited by laser-induced CVD as active layers in chemical gas sensors, 291
Chemical vapor deposition
Low-temperature deposition of films from tetrakis(dimethylamido)titanium and ammonia, 10
Ir and Ru bottom electrodes for (Ba, Sr)$TiO_3$ thin films deposited by liquid delivery source chemical vapor deposition, 285
$C_{60}(111)$ in-plane structure
In-plane orientational order across $C_{60}(111)/Au(111)$ interfaces, 296
Coating
Adhesion enhancement of diamond coatings on WC tools by high energy ion irradiation, 163
Composite coatings
Preparation and characterization of composite tin/Chevrel phase $PbMo_6S_8$ and tin/titanium–niobium carbonitride $Ti_{0.63}Nb_{0.34}C_{0.38}N_{0.58}$, 23
Conductivity measurements
Influence of gas phase chemistry on the properties of hydrogenated amorphous silicon and silicon–carbon alloys grown by HACVD, 115
Coordination behaviour
Langmuir–Blodgett films of a polymerisable *N,N′*-disubstituted dithiooxamide coordination compound, 243
Copper(I) bromide CuBr
Preparation of thin films of copper(I) bromide by r.f. sputtering: morphology and electrical properties, 31
Copper sulphide
The formation of copper sulphide semiconductors inside Langmuir–Blodgett films of Cu(II) ion complexes, 251
Corrosion
Multi-pass overlapping laser glazing of FeCrPC and CoNiSiB alloys, 199
Crystalline structure
Nanomechanic properties of epitaxial α-Fe films grown on $CaF_2(111)/Si(111)$, 178
Crystallization
Change in surface morphologies with pulsed-laser-deposition-temperature for $SrTiO_3$ and $Ba_{0.7}Sr_{0.3}TiO_3$ thin films on Pt electrodes, 63
Calorimetric study of amorphous Sb–Se thin films, 79
Crystal structure
Effects of substrate materials and annealing temperature on crystal structure and epitaxy of $La_{0.7}Sr_{0.3}MnO_3$ films via dipping-pyrolysis process, 99
$CuIn_{1-x}Ga_xSe_2$ thin films
New approaches to obtain $CuIn_{1-x}Ga_xSe_2$ thin films by combining electrodeposited and evaporated precursors, 93

Elsevier Science S.A.
*PII* S0040-6090(98)00834-7

Current–voltage characteristics
Preparation of thin films of copper(I) bromide by r.f. sputtering: morphology and electrical properties, 31
Cu–Se
New approaches to obtain $CuIn_{1-x}Ga_xSe_2$ thin films by combining electrodeposited and evaporated precursors, 93
Depth profiling
Depth inhomogeneity of deposited thin films: application to semi-insulating polycrystalline silicon films, 53
Diacetylene derivative
Langmuir–Blodgett films of a polymerisable *N,N'*-disubstituted dithiooxamide coordination compound, 243
Diamond
Adhesion enhancement of diamond coatings on WC tools by high energy ion irradiation, 163
Characteristics of carbon nitride films prepared by magnetic filtered plasma stream, 217
Dielectric constant
Microstructure of $Ta_2O_5$ films grown by the anodization of $TaN_x$, 6
Dielectric properties
Change in surface morphologies with pulsed-laser-deposition-temperature for $SrTiO_3$ and $Ba_{0.7}Sr_{0.3}TiO_3$ thin films on Pt electrodes, 63
Dissolution rate
In situ measurements of ultrathin silicon oxide dissolution rates, 170
Dithiooxamide ligands
Langmuir–Blodgett films of a polymerisable *N,N'*-disubstituted dithiooxamide coordination compound, 243
Duplex treatment
The effect of Ti ion bombardment on the interfacial structure between TiN and iron nitride, 146

Elastomers and plastics
Analysis of X-ray reflectivity curves of non-Gaussian surfaces, 1
Electrical properties
Gas sensitivity studies by optical spectroscopy below the absorption edge in tin oxide thin film sensors, 275
Electrochemical vapor deposition
Preparation of ceria thin films and microtubes by vapor-phase deposition using NiO as oxygen source, 18
Electrochemistry
Preparation and characterization of composite tin/Chevrel phase $PbMo_6S_8$ and tin/titanium–niobium carbonitride $Ti_{0.63}Nb_{0.34}C_{0.38}N_{0.58}$, 23
Electrodeposited precursor
New approaches to obtain $CuIn_{1-x}Ga_xSe_2$ thin films by combining electrodeposited and evaporated precursors, 93
Electronic devices
Electric field effect on exciton absorption in size-quantized semiconductor film, 209
Electron scattering
Numerical modelling of the processes of exposure and development in electron beam lithography on high-temperature superconductor thin films, 222
Epilayers
Growth and characterization of IV–VI semiconductor heterostructures on (100) $BaF_2$, 126
Epitaxial $\alpha$-Fe
Nanomechanic properties of epitaxial $\alpha$-Fe films grown on $CaF_2(111)/Si(111)$, 178
Epitaxial orientational reordering
In-plane orientational order across $C_{60}(111)/Au(111)$ interfaces, 296
Epitaxy
Effects of substrate materials and annealing temperature on crystal structure and epitaxy of $La_{0.7}Sr_{0.3}MnO_3$ films via dipping-pyrolysis process, 99
Influences of substrates and substrate temperatures on characteristics of epitaxial $La_{0.5}Sr_{0.5}CoO_3$ thin films, 304
Erbium
Structural characterisation of $Er^{3+}$ doped sol–gel $TiO_2$ planar optical waveguides, 59

Field effect
Electric field effect on exciton absorption in size-quantized semiconductor film, 209
Film stress
Influence of stress in thin film modulus measurements by the vibrating reed technique, 153
Finite element method
Numerical simulation for determining the mechanical properties of thin metal films using depth-sensing indentation technique, 183
Fluorescence
Studies on mixed europium complex/octadecylamine monolayers with various molar ratios on an aqueous solution subphase surface, 235
Fourier-transform infrared spectroscopy (FTIR)
Surface characterization of a potential photoactive LC coupling agent, 42
Fourier transform infrared spectroscopy
Characteristics of carbon nitride films prepared by magnetic filtered plasma stream, 217
Friction and wear
Friction and wear behaviour of carbon ion-implanted PS against steel, 158

Gallium selenide
Optical transitions in InSe/GaSe superlattices, 194
Gas phase parameters
Influence of gas phase chemistry on the properties of hydrogenated amorphous silicon and silicon–carbon alloys grown by HACVD, 115
Germanium
Synthesis of Ge nanocrystals in thermal $SiO_2$ films by $Ge^+$ ion implantation, 68
Graphite target
Optical studies of carbon nitride thin films deposited by reactive pulsed laser ablation of a graphite target in low pressure ammonia, 72
Growth mechanism
Influences of substrates and substrate temperatures on characteristics of epitaxial $La_{0.5}Sr_{0.5}CoO_3$ thin films, 304

Hemicyanine
Properties of polymeric Langmuir–Blodgett films containing sulphonyl-substituted azobenzene moieties for second harmonic generation, 227
Heterostructure
Fabrication and characterization of epitaxial AlN/TiN bilayers on sapphire, 37
Heterostructures
Growth and characterization of IV–VI semiconductor heterostructures on (100) $BaF_2$, 126
Optical transitions in InSe/GaSe superlattices, 194
HF solutions
In situ measurements of ultrathin silicon oxide dissolution rates, 170
Hydrogen assisted chemical vapour deposition
Influence of gas phase chemistry on the properties of hydrogenated amorphous silicon and silicon–carbon alloys grown by HACVD, 115

Interface
The effect of Ti ion bombardment on the interfacial structure between TiN and iron nitride, 146
Ion implantation
Synthesis of Ge nanocrystals in thermal $SiO_2$ films by $Ge^+$ ion implantation, 68

Friction and wear behaviour of carbon ion-implanted PS against steel, 158
IR light
γ-AgI films by iodization at ambient temperature, 110
Irradiation
Adhesion enhancement of diamond coatings on WC tools by high energy ion irradiation, 163

Langmuir–Blodgett film
The formation of copper sulphide semiconductors inside Langmuir–Blodgett films of Cu(II) ion complexes, 251
Studies on mixed europium complex/octadecylamine monolayers with various molar ratios on an aqueous solution subphase surface, 235
Langmuir–Blodgett films of a polymerisable *N,N′*-disubstituted dithiooxamide coordination compound, 243
Langmuir–Blodgett films (LB films)
Langmuir and Langmuir–Blodgett films of a homopolymer of Disperse Red-13, 257
Lanthanides
Studies on mixed europium complex/octadecylamine monolayers with various molar ratios on an aqueous solution subphase surface, 235
Laser ablation
Fabrication and characterization of epitaxial AlN/TiN bilayers on sapphire, 37
Change in surface morphologies with pulsed-laser-deposition-temperature for $SrTiO_3$ and $Ba_{0.7}Sr_{0.3}TiO_3$ thin films on Pt electrodes, 63
Influences of substrates and substrate temperatures on characteristics of epitaxial $La_{0.5}Sr_{0.5}CoO_3$ thin films, 304
Laser irradiation
Multi-pass overlapping laser glazing of FeCrPC and CoNiSiB alloys, 199
$La_{0.7}Sr_{0.3}MnO_3$ films
Effects of substrate materials and annealing temperature on crystal structure and epitaxy of $La_{0.7}Sr_{0.3}MnO_3$ films via dipping-pyrolysis process, 99
L-CVD
Organotin films deposited by laser-induced CVD as active layers in chemical gas sensors, 291

Lead titanate/vinylidene fluoride–trifluoroethylene (PT/P(VDF–TrFE)) composite
Pyroelectric properties of $PbTiO_3$/P(VDF–TrFE) 0–3 nanocomposite films, 270
Liquid delivery
Ir and Ru bottom electrodes for (Ba, Sr)$TiO_3$ thin films deposited by liquid delivery source chemical vapor deposition, 285
Liquid phase epitaxy
Growth and characterization of IV–VI semiconductor heterostructures on (100) $BaF_2$, 126
Lithium intercalation
Redox properties of nanoporous $TiO_2$ (anatase) surface modified with phosphotungstic acid, 141

Measurements
Gas sensitivity studies by optical spectroscopy below the absorption edge in tin oxide thin film sensors, 275
Mechanical properties
Numerical simulation for determining the mechanical properties of thin metal films using depth-sensing indentation technique, 183
Metal films
Numerical simulation for determining the mechanical properties of thin metal films using depth-sensing indentation technique, 183
Microstructure
Microstructure of $Ta_2O_5$ films grown by the anodization of $TaN_x$, 6
Microtube
Preparation of ceria thin films and microtubes by vapor-phase deposition using NiO as oxygen source, 18
Modulus
Study of out-of-plane elastic properties of PMDA-ODA and BPDA-PDA polyimide thin films, 203
Molecular beam epitaxy
New optical properties of Ge self-organized quantum dots, 174
Monolayers
Studies on mixed europium complex/octadecylamine monolayers with various molar ratios on an aqueous solution subphase surface, 235
Langmuir and Langmuir–Blodgett films of a homopolymer of Disperse Red-13, 257
Multilayer
The formation of copper sulphide semiconductors inside Langmuir–Blodgett films of Cu(II) ion complexes, 251
Langmuir and Langmuir–Blodgett films of a homopolymer of Disperse Red-13, 257

Nanocomposite
Pyroelectric properties of $PbTiO_3$/P(VDF–TrFE) 0–3 nanocomposite films, 270
Nanocrystallite
Low-temperature deposition of films from tetrakis(dimethylamido)titanium and ammonia, 10
Nanoindentation
Nanomechanic properties of epitaxial α-Fe films grown on $CaF_2(111)/Si(111)$, 178
Numerical simulation for determining the mechanical properties of thin metal films using depth-sensing indentation technique, 183
Nanomechanic properties
Nanomechanic properties of epitaxial α-Fe films grown on $CaF_2(111)/Si(111)$, 178
Nanoporous
Redox properties of nanoporous $TiO_2$ (anatase) surface modified with phosphotungstic acid, 141
Nanostructures
Synthesis of Ge nanocrystals in thermal $SiO_2$ films by $Ge^+$ ion implantation, 68
Numerical modelling of the processes of exposure and development in electron beam lithography on high-temperature superconductor thin films, 222
Nickel oxide
Preparation of ceria thin films and microtubes by vapor-phase deposition using NiO as oxygen source, 18
Nitrides
Characteristics of carbon nitride films prepared by magnetic filtered plasma stream, 217

Optical investigations
Optical studies of carbon nitride thin films deposited by reactive pulsed laser ablation of a graphite target in low pressure ammonia, 72
Optical properties
Depth inhomogeneity of deposited thin films: application to semi-insulating polycrystalline silicon films, 53
Optical properties of very thin (< 100 nm) sol–gel $TiO_2$ films, 188
Optical transitions in InSe/GaSe superlattices, 194
Gas sensitivity studies by optical spectroscopy below the absorption edge in tin oxide thin film sensors, 275
Optical spectroscopy
Optical properties of very thin (< 100 nm) sol–gel $TiO_2$ films, 188
Organotin films
Organotin films deposited by laser-induced CVD as active layers in chemical gas sensors, 291

Oriented silver films
Surface characterization of oriented silver films on Si (100) substrates using scanning tunnelling microscopy, 105
Out-of-plane
Study of out-of-plane elastic properties of PMDA-ODA and BPDA-PDA polyimide thin films, 203

Phase transition
Influence of gas phase chemistry on the properties of hydrogenated amorphous silicon and silicon–carbon alloys grown by HACVD, 115
Calorimetric study of amorphous Sb–Se thin films, 79
Phosphotungstic acid
Redox properties of nanoporous $TiO_2$ (anatase) surface modified with phosphotungstic acid, 141
Photoluminescence
New optical properties of Ge self-organized quantum dots, 174
Photovoltaic properties
Growth of $CuIn_3Se_5$ layer on $CuInSe_2$ films and its effect on the photovoltaic properties of $In_2Se_3/CuInSe_2$ solar cells, 265
PMDA-ODA
Study of out-of-plane elastic properties of PMDA-ODA and BPDA-PDA polyimide thin films, 203
Polyimide
Study of out-of-plane elastic properties of PMDA-ODA and BPDA-PDA polyimide thin films, 203
Polymeric Langmuir–Blodgett films
Properties of polymeric Langmuir–Blodgett films containing sulphonyl-substituted azobenzene moieties for second harmonic generation, 227
Polymers
Analysis of X-ray reflectivity curves of non-Gaussian surfaces, 1
Langmuir and Langmuir–Blodgett films of a homopolymer of Disperse Red-13, 257
Polyoxometalates
Redox properties of nanoporous $TiO_2$ (anatase) surface modified with phosphotungstic acid, 141
Polystyrene
Friction and wear behaviour of carbon ion-implanted PS against steel, 158
Pyroelectric sensor
Pyroelectric properties of $PbTiO_3/P(VDF–TrFE)$ 0–3 nanocomposite films, 270

Quantum dot
New optical properties of Ge self-organized quantum dots, 174
Quantum effects
Electric field effect on exciton absorption in size-quantized semiconductor film, 209

Raman measurements
Influence of gas phase chemistry on the properties of hydrogenated amorphous silicon and silicon–carbon alloys grown by HACVD, 115
Reflection spectroscopy
Depth inhomogeneity of deposited thin films: application to semi-insulating polycrystalline silicon films, 53

Scanning tunnelling microscopy
Surface characterization of oriented silver films on Si (100) substrates using scanning tunnelling microscopy, 105
Second harmonic generation
Properties of polymeric Langmuir–Blodgett films containing sulphonyl-substituted azobenzene moieties for second harmonic generation, 227
Selenides
Calorimetric study of amorphous Sb–Se thin films, 79
Self-organize
New optical properties of Ge self-organized quantum dots, 174
Semiconductor
The formation of copper sulphide semiconductors inside Langmuir–Blodgett films of Cu(II) ion complexes, 251
Sensors
Gas sensitivity studies by optical spectroscopy below the absorption edge in tin oxide thin film sensors, 275
Silicon oxide
Synthesis of Ge nanocrystals in thermal $SiO_2$ films by $Ge^+$ ion implantation, 68
In situ measurements of ultrathin silicon oxide dissolution rates, 170
Silver foils
$\gamma$-AgI films by iodization at ambient temperature, 110
Si (100) substrates
Surface characterization of oriented silver films on Si (100) substrates using scanning tunnelling microscopy, 105
Solar cell
Growth of $CuIn_3Se_5$ layer on $CuInSe_2$ films and its effect on the photovoltaic properties of $In_2Se_3/CuInSe_2$ solar cells, 265
Sol–gel
Optical properties of very thin (< 100 nm) sol–gel $TiO_2$ films, 188
r.f. Sputtering
Preparation of thin films of copper(I) bromide by r.f. sputtering: morphology and electrical properties, 31
Structural properties
Influences of substrates and substrate temperatures on characteristics of epitaxial $La_{0.5}Sr_{0.5}CoO_3$ thin films, 304
Substrate temperature
Influence of substrate temperature and target composition on the properties of yttria-stabilized zirconia thin films grown by r.f. reactive magnetron sputtering, 85
Superconductivity
Numerical modelling of the processes of exposure and development in electron beam lithography on high-temperature superconductor thin films, 222
Supercooled vacuum condensates
Size and temperature effects on wetting in supercooled vacuum condensates, 136
Superlattices
Optical transitions in InSe/GaSe superlattices, 194
Surface melting
Multi-pass overlapping laser glazing of FeCrPC and CoNiSiB alloys, 199
Surface morphology
Change in surface morphologies with pulsed-laser-deposition-temperature for $SrTiO_3$ and $Ba_{0.7}Sr_{0.3}TiO_3$ thin films on Pt electrodes, 63
Surface structure
Preparation and characterization of composite tin/Chevrel phase $PbMo_6S_8$ and tin/titanium–niobium carbonitride $Ti_{0.63}Nb_{0.34}C_{0.38}N_{0.58}$, 23

Tantalum oxide
Microstructure of $Ta_2O_5$ films grown by the anodization of $TaN_x$, 6
Target composition
Influence of substrate temperature and target composition on the properties of yttria-stabilized zirconia thin films grown by r.f. reactive magnetron sputtering, 85
Tetrakis(dimethylamido)titanium (TDMAT)
Low-temperature deposition of films from tetrakis(dimethylamido)titanium and ammonia, 10
Thin film
Preparation of ceria thin films and microtubes by vapor-phase deposition using NiO as oxygen source, 18
Study of out-of-plane elastic properties of PMDA-ODA and BPDA-PDA polyimide thin films, 203

Thin film structure and morphology
Analysis of X-ray reflectivity curves of non-Gaussian surfaces, 1
Tin
Preparation and characterization of composite tin/Chevrel phase $PbMo_6S_8$ and tin/titanium–niobium carbonitride $Ti_{0.63}Nb_{0.34}C_{0.38}N_{0.58}$, 23
Tin oxide
Gas sensitivity studies by optical spectroscopy below the absorption edge in tin oxide thin film sensors, 275
Titanium nitride
Fabrication and characterization of epitaxial AlN/TiN bilayers on sapphire, 37
Torsional vibration
Influence of stress in thin film modulus measurements by the vibrating reed technique, 153
Transmission electron microscopy
Microstructure of $Ta_2O_5$ films grown by the anodization of $TaN_x$, 6
Structural characterisation of $Er^{3+}$ doped sol–gel $TiO_2$ planar optical waveguides, 59

Vibrating reed
Influence of stress in thin film modulus measurements by the vibrating reed technique, 153

Waveguides
Structural characterisation of $Er^{3+}$ doped sol–gel $TiO_2$ planar optical waveguides, 59
Wetting
Size and temperature effects on wetting in supercooled vacuum condensates, 136
Wipeoffs
Growth and characterization of IV–VI semiconductor heterostructures on (100) $BaF_2$, 126

XPS
Redox properties of nanoporous $TiO_2$ (anatase) surface modified with phosphotungstic acid, 141
X-ray photoelectron spectroscopy (XPS)
Surface characterization of a potential photoactive LC coupling agent, 42
XPS analyses
Friction and wear behaviour of carbon ion-implanted PS against steel, 158
X-ray diffraction
Growth of $CuIn_3Se_5$ layer on $CuInSe_2$ films and its effect on the photovoltaic properties of $In_2Se_3/CuInSe_2$ solar cells, 265
X-ray photoelectron spectroscopy
Characteristics of carbon nitride films prepared by magnetic filtered plasma stream, 217
X-ray reflectivity
Surface characterization of a potential photoactive LC coupling agent, 42
X-ray reflectometry
Analysis of X-ray reflectivity curves of non-Gaussian surfaces, 1

Young's modulus
Influence of stress in thin film modulus measurements by the vibrating reed technique, 153

$ZrO_2$–$Y_2O_3$ films
Influence of substrate temperature and target composition on the properties of yttria-stabilized zirconia thin films grown by r.f. reactive magnetron sputtering, 85